# Diffusion

Diffusion - Mass transport by atomic motion

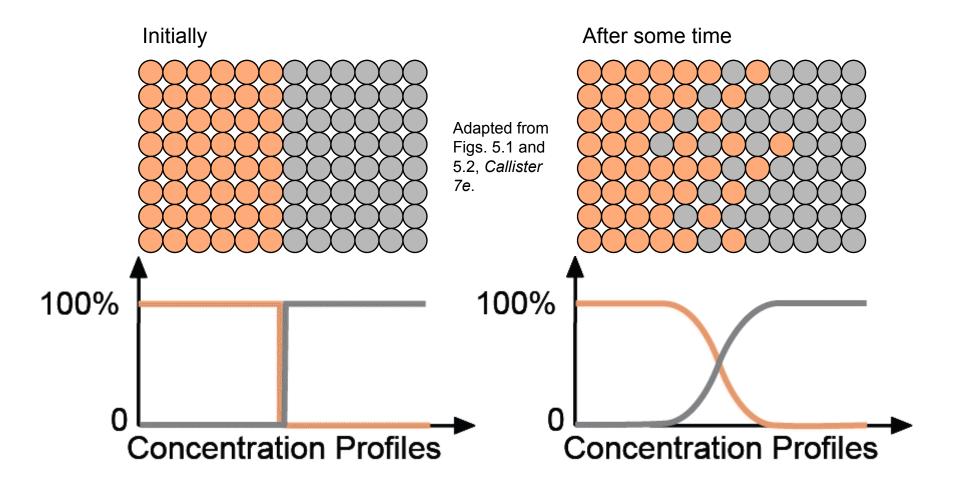
#### Mechanisms

- •Gases & Liquids random (Brownian) motion
- •Solids vacancy diffusion or interstitial diffusion

Interdiffusion: In an alloy, atoms tend to migrate from regions of high conc. to regions of low conc.

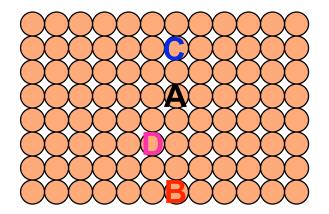
Self-diffusion: In an elemental solid, atoms also migrate.

# Interdiffusion

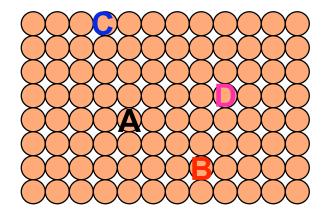


# Self-diffusion

Label some atoms



#### After some time



# **Diffusion mechanisms**

#### Conditions:

- •There must be an empty site available
- Atoms must have the energy to make the jump

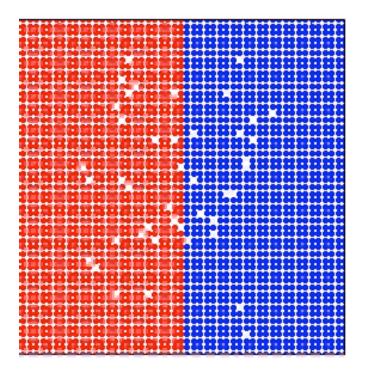
#### Vacancy Diffusion:

- atoms exchange with vacancies
- · applies to substitutional impurities atoms
- rate depends on:
  - --number of vacancies
  - --activation energy to exchange.

increasing elapsed time

## **Diffusion simulation**

- Simulation of interdiffusion across an interface:
- Rate of substitutional diffusion depends on:
   -vacancy concentration
   -frequency of jumping.



(Courtesy P.M. Anderson)

# Diffusion flux

How do we quantify the amount or rate of diffusion?

$$J = Flux = \frac{moles (or mass) diffusing}{(surface area)(time)} = \frac{mol}{cm^2 s} or \frac{kg}{m^2 s}$$

Measured empirically

- Make thin film (membrane) of known surface area
- Impose concentration gradient
- Measure how fast atoms or molecules diffuse through the membrane

$$J = \frac{M}{At} = \frac{I}{A} \frac{dM}{dt}$$

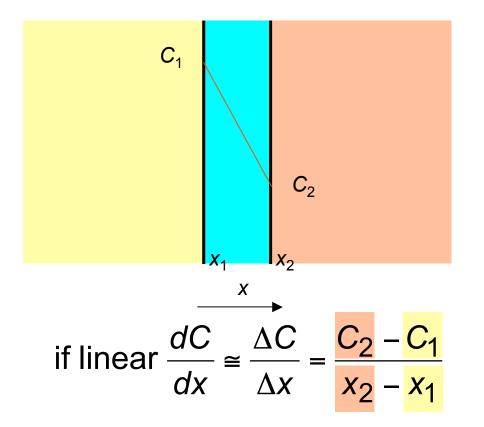
$$M = mass \\ diffused \\ time$$

## Steady-state diffusion

Rate of diffusion independent of time

Flux proportional to concentration gradient =





Fick's first law of diffusion

$$J = -D\frac{dC}{dx}$$

D = diffusion coefficient

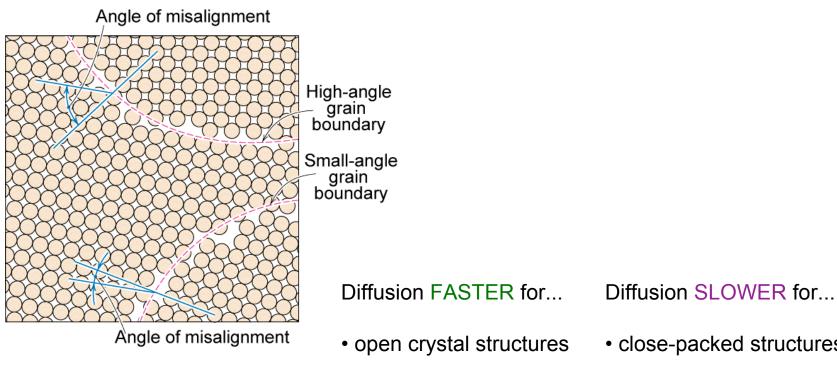
#### Diffusion and temperature

• Diffusion coefficient increases with increasing *T*.

$$D = D_o \exp \left(-\frac{Q_d}{RT}\right)$$

- D = diffusion coefficient [m<sup>2</sup>/s]
- $D_o$  = pre-exponential [m<sup>2</sup>/s]
- $Q_d$  = activation energy [J/mol or eV/atom]
- R = gas constant [8.314 J/mol-K]
- *T* = absolute temperature [K]

# Diffusion paths

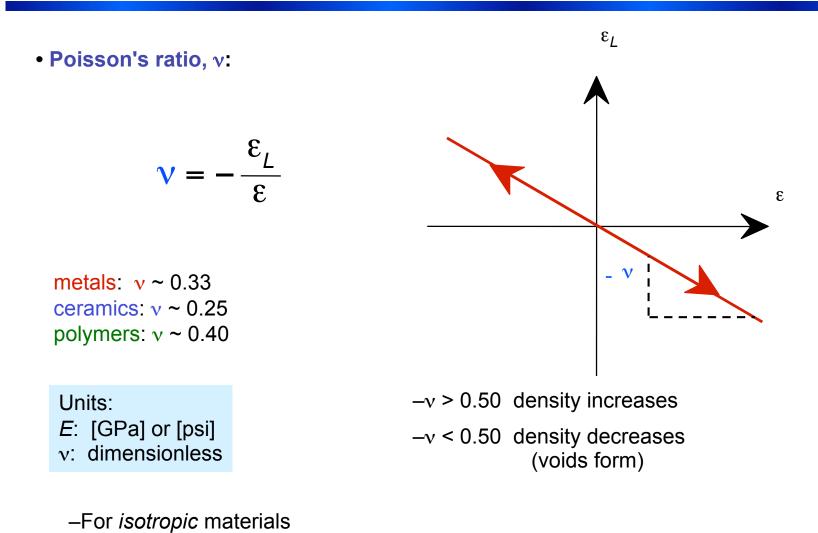


- materials w/secondary bonding
- smaller diffusing atoms
- lower density materials

- close-packed structures
- materials w/covalent bonding
- larger diffusing atoms
- higher density materials

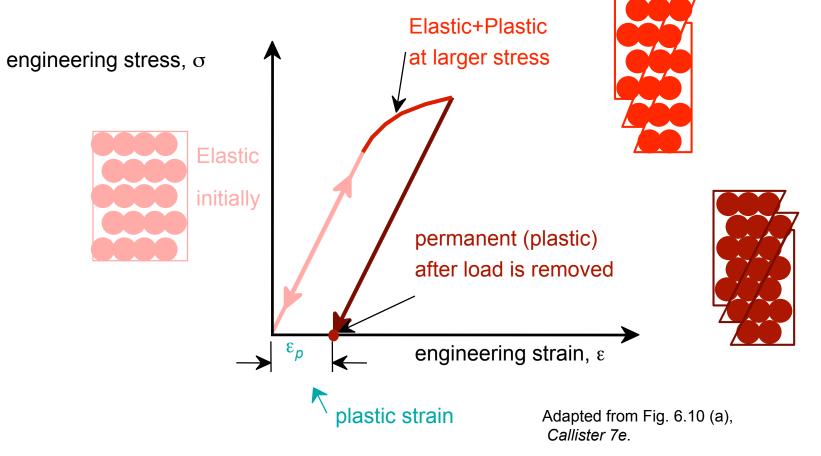
#### Elastic properties of materials

E = 2G (1+v)



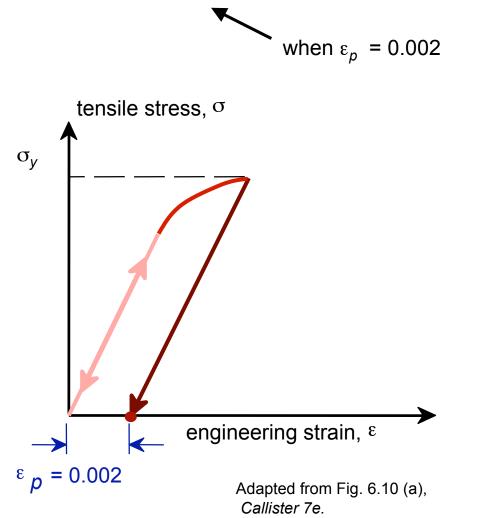
# **Plastic deformation**





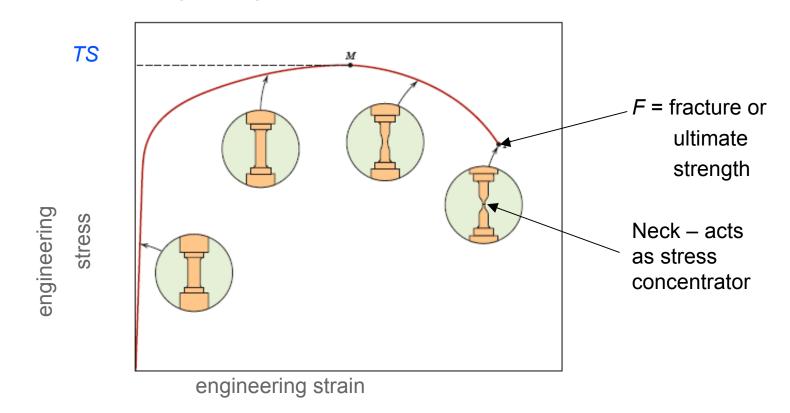
# Yield strength, $\sigma_v$

• Stress at which *noticeable* plastic deformation has occurred.



# Tensile strength, TS

• Maximum stress on engineering stress-strain curve.



- Metals: occurs when noticeable necking starts.
- Polymers: occurs when polymer backbone chains are aligned and about to break.

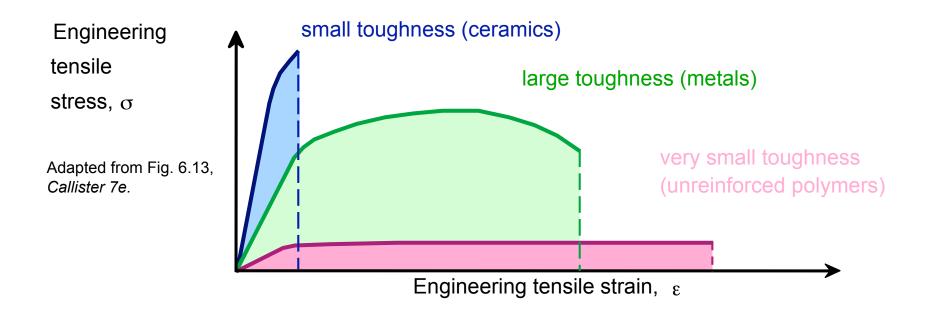
# Ductility

*<sup>-</sup> <sup>L</sup> <sub>o</sub>* x 100 Plastic tensile strain at failure: % EL = Lo smaller %EL Engineering tensile stress,  $\sigma$ larger %EL  $A_o$  $L_o$  $A_f$  $L_{f}$ Adapted from Fig. 6.13, Callister 7e. Engineering tensile strain,  $\epsilon$  $\% RA = A_{o} - A_{f} \times 100$ • Another ductility measure: Α

0

# Toughness

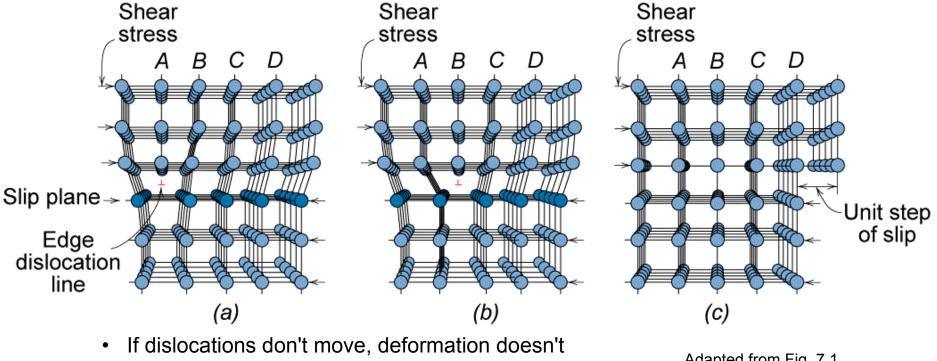
- Energy to break a unit volume of material
- Approximate by the area under the stress-strain curve.



Brittle fracture: elastic energy Ductile fracture: elastic + plastic energy

# Dislocation and plastic deformation

• Cubic & hexagonal metals - plastic deformation by plastic shear or slip where one plane of atoms slides over adjacent plane by defect motion (dislocations).

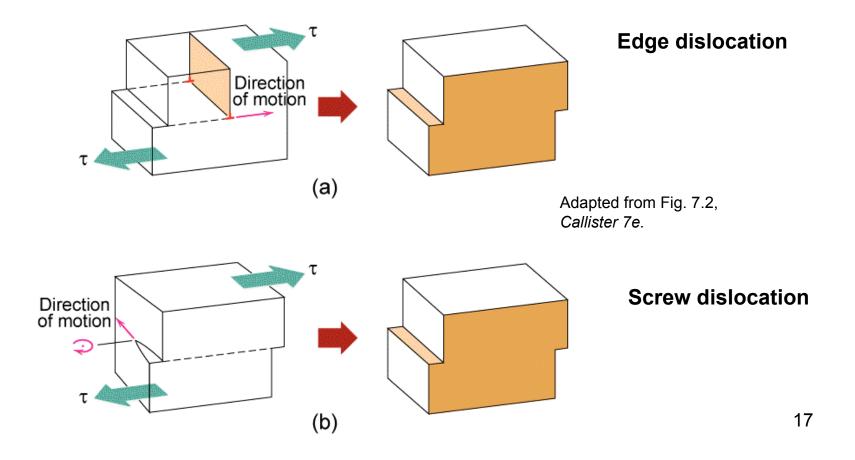


occur!

Adapted from Fig. 7.1, *Callister 7e.* 

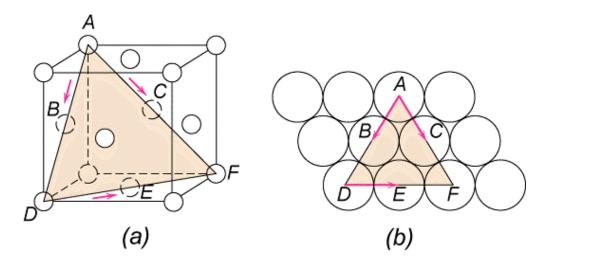
## **Dislocation motion**

- Dislocation moves along slip plane in slip direction perpendicular to dislocation line
- Edge dislocations move parallel to the applied force, screw dislocations move perpendicular to the applied force



#### **Deformation mechanisms**

- Slip System
  - Slip plane plane allowing easiest slippage
  - Slip direction direction of movement

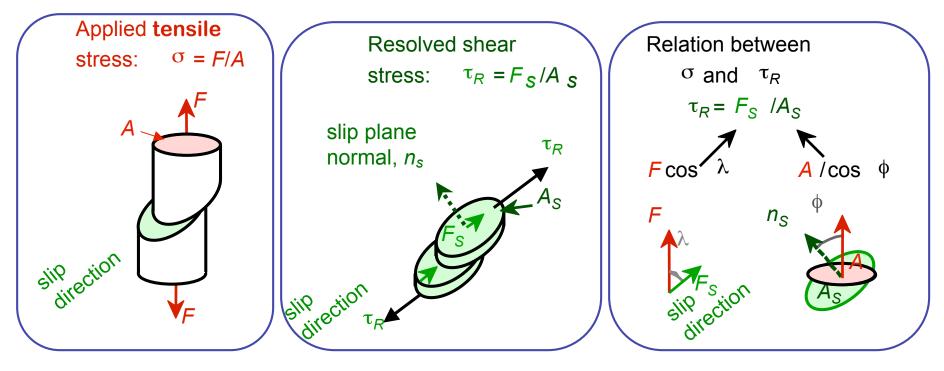


Adapted from Fig. 7.6, *Callister 7e.* 

- FCC Slip occurs on {111} planes (close-packed) in <110> directions (close-packed)
  - => total of 12 slip systems in FCC

# Slip in single crystals

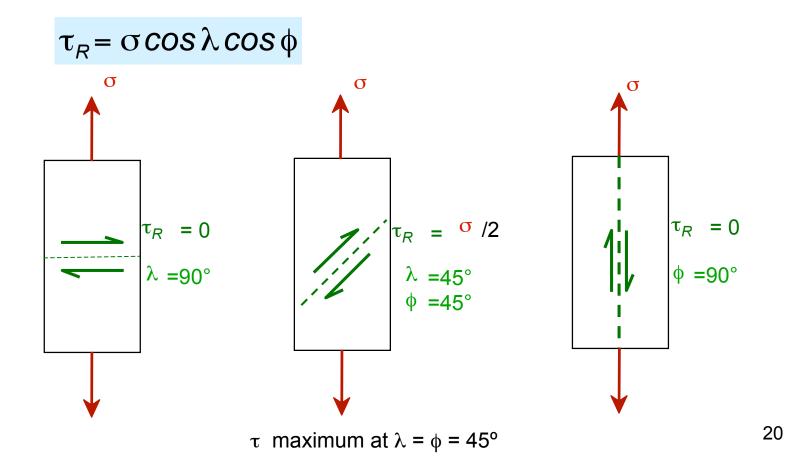
- Crystals slip due to a resolved shear stress,  $\tau_R$ .
- Applied tension can produce such a stress.



$$\tau_R = \sigma \cos \lambda \cos \phi$$

#### Critical resolved shear stress

- Condition for dislocation motion:  $\tau_R > \tau_{CRSS}$
- Crystal orientation can make it easy or hard to move dislocation



# Slip motion in polycrystals

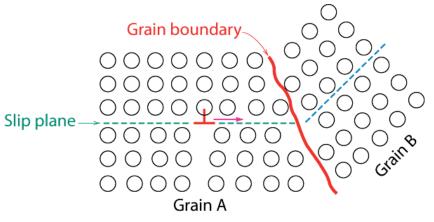
- Stronger grain boundaries pin deformations
- Slip planes & directions  $(\lambda, \phi)$  change from one crystal to another.
- $\tau_R$  will vary from one crystal to another.
- The crystal with the largest  $\tau_{R}$  yields first.
- Other (less favorably oriented) crystals yield later.



Adapted from Fig. 7.10, *Callister 7e.* (Fig. 7.10 is courtesy of C. Brady, National Bureau of Standards [now the National Institute of Standards and Technology, Gaithersburg, MD].)

#### Strategies for strengthening: grain size reduction

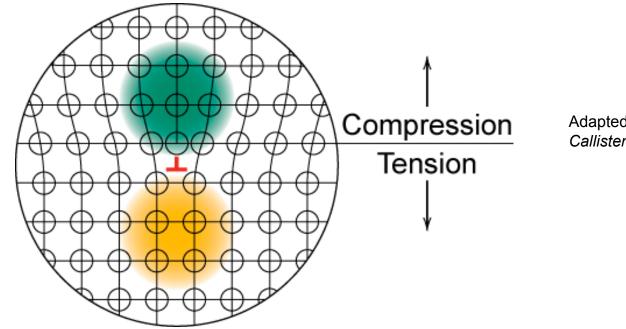
- Grain boundaries are barriers to slip.
- Barrier "strength" increases with increasing angle of misorientation.
- Smaller grain size: more barriers to slip.



Adapted from Fig. 7.14, *Callister 7e.* (Fig. 7.14 is from *A Textbook of Materials Technology*, by Van Vlack, Pearson Education, Inc., Upper Saddle River, NJ.)

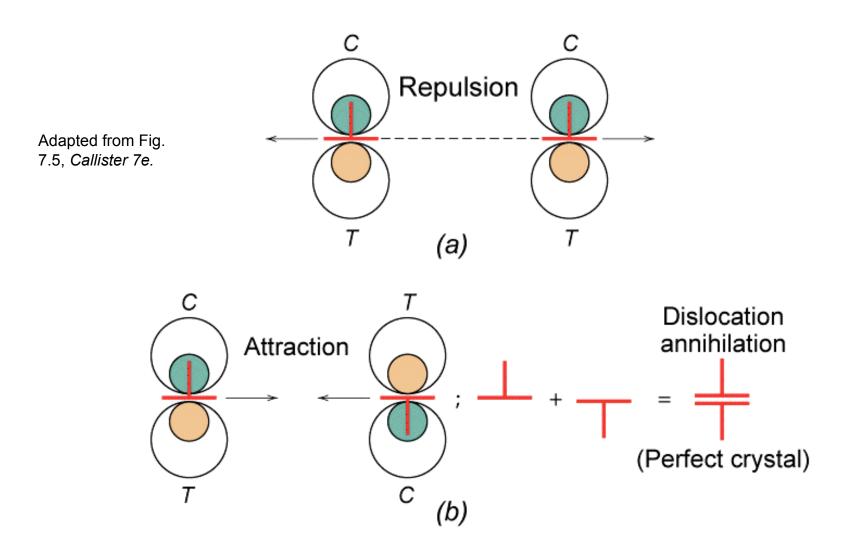
• Hall-Petch Equation: 
$$\sigma_{yield} = \sigma_o + k_y d^{-1/2}$$

### Strategies for strengthening: solid solutions



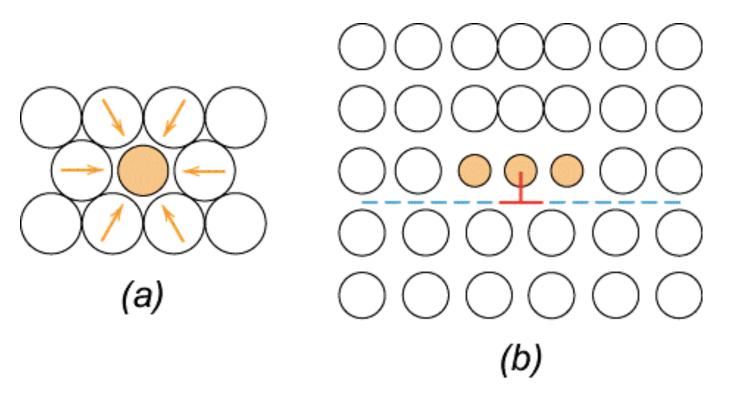
Adapted from Fig. 7.4, *Callister 7e.* 

## Effects of stress at dislocations



# Strengthening by alloying

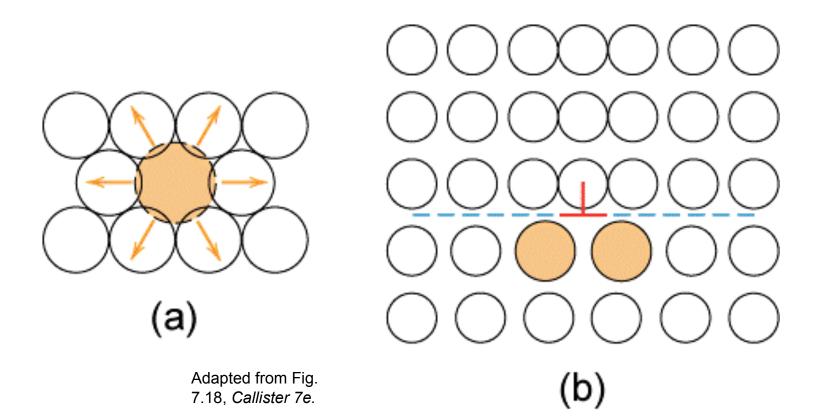
- small impurities tend to concentrate at dislocations
- reduce mobility of dislocation ... increase strength



Adapted from Fig. 7.17, *Callister 7e.* 

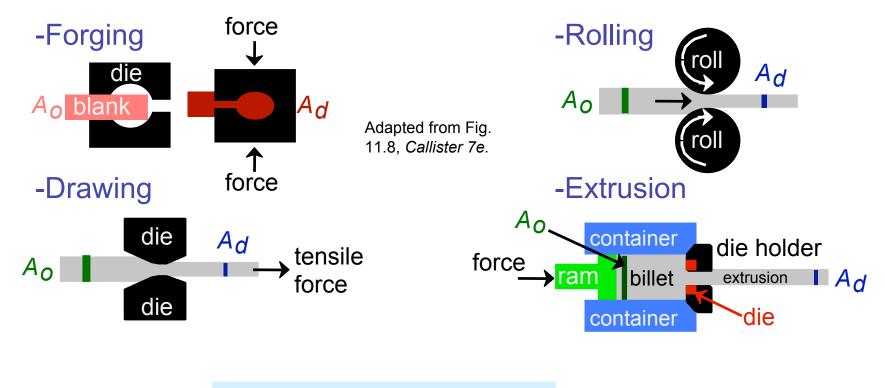
# Strengthening by alloying

• large impurities concentrate at dislocations on low density side



# Strategies for strengthening: Cold work (%CW)

- Room temperature deformation.
- Common forming operations change the cross sectional area:



$$%CW = \frac{A_o - A_d}{A_o} \times 100$$

## Impact of cold work

As cold work is increased

- Yield strength  $(\sigma_v)$  increases.
- Tensile strength (*TS*) increases.
- Ductility (%*EL* or %*AR*) decreases.

